



Mechanically polishing electroplated Nb₃Sn for higher accelerating gradients

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As the demand for more efficient SRF technology continues to rise, so does the need to improve the performance of Nb₃Sn, the most promising alternative to niobium. Leveraging recent breakthroughs in Nb₃Sn research from Cornell University and Fermilab, namely the electrochemical synthesis-based growth of Nb₃Sn and the centrifugal barrel polishing (CBP) technique to smoothen the final Nb₃Sn film, our primary goal is to reduce surface roughness while preserving the film's quality. We present promising RF results from an electroplated cavity that underwent mechanical polishing using the CBP technique, which showed an increase in the maximum accelerating gradient compared to the baseline test.

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Yes

Footnotes

Funding Agency

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